

IEUVI MASK TWG

Sunday February 22, 2009



1:00 PM – 1:10 PM	Introduction and Greetings	<i>K. Orvek, SEMATECH</i>
1:10 PM – 2:00 PM	SEMI Standards Updates <ul style="list-style-type: none">• 4466B Draft for Carrier – Voting End February 18• P40 Slightly Revised Draft for Voting April 13• P37 New Draft Version – Specifications Moving to ITRS	<i>L. He, Intel</i> <i>J. Zimmerman, ASML</i> <i>K. Orvek, SEMATECH</i>
2:00 PM – 2:50 PM	ITRS Roadmap, Specifications for EUVL Masks 2010-2012	
2:50 PM – 3:10 PM	Break	
3:10 PM – 3:20 PM	Review Mask Infrastructure Readiness Survey Results	<i>K. Orvek, SEMATECH</i>
3:20 PM – 4:50 PM	Focus Topics: Mask Defect Density <ul style="list-style-type: none">• Blank Defects• Real-World Printing of EUV Mask Defects• Covering Defects – Fiducial Status	<i>H. Yun, SEMATECH</i> <i>O. Wood, AMD</i> <i>S. Huh, SEMATECH</i>
4:50 PM – 5:00 PM	Wrap Up and Plans for Next TWG Meeting	<i>K. Orvek, SEMATECH</i>
5:00 PM – 6:00 PM	Extra Session: In-Depth Discussion of Fiducials	<i>S. Huh, SEMATECH</i> <i>P. Yang, Intel</i>



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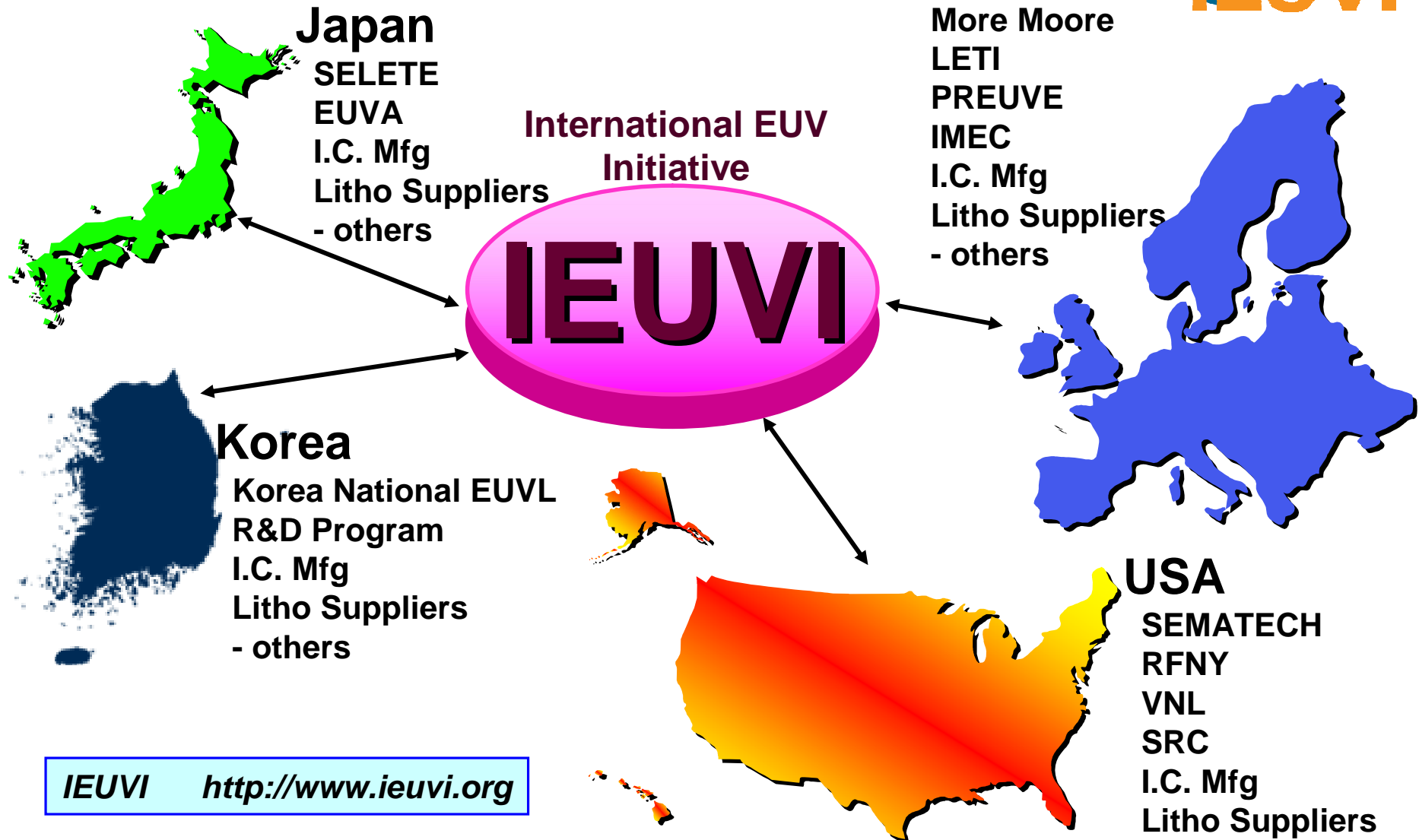
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International EUV Initiative



International EUV Initiative



IEUVI Source TWG

IEUVI Optics TWG

IEUVI Resist TWG

IEUVI Mask TWG



**International EUV Initiative
Executive Board**

<http://www.ieuvi.org>

Executive Chair: Paolo Gargini (next meeting 02/27/09)

- *Regular coordination meetings*
- *Technical Working Groups*
- *Benchmarking data exchange*
- *Co-sponsorship of workshops*